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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Arpan P. Mahorowala et al.

Serial No.: 09/902,728

Filed: July 12, 2001

For: METHOD TO PREVENT
PATTERN COLLAPSE IN
FEATURES ETCHED IN SULFUR
DIOXIDE-CONTAINING PLASMAS:
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Examiner: Barreca, Nicole M.

Art Unit: 1756

Atty Docket: YOR920000789US1

OFFICIAL

RESPONSE AND AMENDMENT UNDER 37 CFR § 1.111Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The Applicants submit the following Amendment and Remarks in response to the Office
Action dated October 27, 2003.

#14,910
Amendments to the Claims

this paper; and

Claims that begins on page 2 of

Remarks/Arguments begin on ~~page 3~~ of this paper.

The Applicants further submit a Declaration under 37 CFR 1.131, attached on a
separate sheet.